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PROPERTIES OF THICK EVAPORATED LAYERS OF PbTe (*)

C. S. Evans and J. S. Seeley
Department of Applied Physical Sciences, University of Reading, England

Résumé. — La transparence optique des couches monocristallines de PbTe peut varier après un traitement thermique suivant l'évaporation. Les monocouches ont quelques microns d'épaisseur et le recuit fait décroître la densité de porteurs d'environ \(10^{18}\) cm\(^{-3}\) (type \(n\)) à \(10^{17}\) cm\(^{-3}\) ; le matériau de la source est à \(10^{19}\) cm\(^{-3}\) (type \(p\)). Le processus semblerait faire intervenir la diffusion de O\(_2\) à un taux de réaction correspondant à une énergie de 0,83 eV.

Abstract. — The changes in the optical transparency of PbTe monolayers induced by post-evaporation heat treatment are described. The monolayers are typically a few microns in thickness and heat treatment reduces the carrier density from about \(10^{18}\) (\(n\)-type) per cm\(^3\) to \(10^{17}\) per cm\(^3\); the source material is \(10^{19}\) (\(p\)-type) per cm\(^3\). The process seems to involve the diffusion of O\(_2\) at a reaction rate equivalent to an energy of 0.83 eV.

1. Introduction. — During a programme to develop multilayer filter techniques for the infrared an intensive study has been made of the suitability of PbTe as a high-index material for filters for the region 5-25 \(\mu\). The method of manufacturing these filters is essentially vacuum evaporation and, when depositing PbTe in alternating combination with a low-index material such as ZnS, control of deposition temperature is most important [2]. On transferring the process into an evaporating unit in our laboratory we have found that optimum temperatures worked out by our collaborators for a different unit in a different laboratory do not necessarily enable us to reproduce the level of transparency they regularly attain. The main difficulty has been established as excessive absorption in our PbTe layers and we have further found that this can be reduced to an acceptable level by post-deposition heat treatment. Our further investigations into this effect have been concentrated on monolayers of PbTe, deposited in various ways, and are described below.

2. Refractive index measurements. — The dispersion and absorption in PbTe due to the presence of carriers can be described by the following relations:

\[
n^2 - \kappa^2 = n_0^2 - \frac{N e^2}{m^* e_0} \cdot \frac{1}{(\omega^2 + g^2)}
\]

\[
2 n \kappa = \frac{\omega}{g} \cdot \frac{N e^2}{m^* e_0} \cdot \frac{1}{(\omega^2 + g^2)}
\]

\(n\)-\(i\kappa\) is the complex refractive index of PbTe \(n_0\) is the refractive index in the absence of carriers (determined by lattice vibration and interband transitions).

\(N\) is the number of carriers per unit volume.

\(\omega\) is frequency of incident radiation.

\(g\) is a damping constant, equated to reciprocal mean free time between carrier collisions.

\(m^*\) the susceptibility effective mass.

The PbTe is evaporated in an 18 inch Edwards unit by standard techniques onto temperature controlled substrates, and thickness is monitored by reflectance at 3.93 \(\mu\). A particular monolayer to be described was evaporated from an alumina crucible onto silicon held at 300 °C and monitored as 12 quarter waves, or approximately 2 \(\mu\) physical thickness. Half the substrate was masked by molybdenum foil to give a sharp step at the edge of the film. The height of the step was determined in an interference microscope. Optical thicknesses were determined at certain specific wavelengths, by measuring the spectral transmission from 3 \(\mu\) to 25 \(\mu\) on a Grubb-Parsons Spectromaster. Figure 1 shows the transmission of the PbTe-coated silicon and for comparison the transmission of the uncoated half of the same substrate. For multiples of half-wave optical thickness, transmission is a maximum and in the absence of absorption or scattering would equal that of the uncoated substrate. For odd multiples of a quarter-wave optical thickness the transmission is a minimum. If the wavelength at transmission

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Extrema is \( \lambda_m \) then for a film on a semi-infinite substrate

\[
m\lambda_m = n(\lambda_m)t + \beta_1 + \beta_2, \tag{3}
\]

(where \( m \) is the integral interference order, \( n(\lambda_m) \) is the refractive index at \( \lambda_m \), \( t \) is the thickness of the film.\( \beta_1, \beta_2 \) are phase changes on reflection at the film surface which become significant for large values of \( \kappa \)).

In practice for a finite substrate, the contribution of \( \kappa \) to the spectral position of the peak is estimated from computations at various \( n \) and \( \kappa \) values. The order of interference is allocated unambiguously from the deposition record, and the wavelength of the extrema can be measured to an accuracy limited principally by the fringe sharpness. This is much more accurate than the step height measurement. Thus values of index can be deduced at these wavelengths with an absolute accuracy of about 0.6 % but relative accuracy of 0.2 % or better.

The transmission of the film shows strong free carrier absorption at long waves; in the absence of absorption there would be a further (second order) peak at about 23 \( \mu \). Also at short waves there is some scattering which is not present under some deposition conditions. The monolayer transmittance is also shown as a ratio of the traces for coated and uncoated halves.

The sample was heated to 340 \( ^\circ \)C in air for about 5 minutes, cooled and measured. For clarity the transmission trace is not shown but the ratio of coated to uncoated transmission is shown. There is a marked increase in transparency which could be due to an overall reduction in either carrier concentration, or in damping constant. In addition however there is a shift of all extrema to longer wavelengths. This is due to an increase in refractive indices and can only be explained by a reduction in the number of carriers.

To interpret the dispersion of this monolayer in terms of free carriers it is necessary to first determine the dispersion due to short wave interband absorption. For this purpose the spectral region shown can be split into two parts. The contribution of carriers decreases with \( \lambda^2 \) and at short wave is relatively small; thus below 8 \( \mu \) the index is largely determined by the interband transitions, and becomes highly dispersive near the absorbing region.

If this dispersion is considered as being due to a simple classical oscillator of resonant wavelength \( \lambda_0 \) then the index \( n_0 \) obeys the relation

\[
\frac{n_0^2 - 1}{n_\infty^2 - 1} = 1 - \frac{\lambda_0^2}{\lambda^2}, \tag{4}
\]

\( n_\infty \) is an asymptotic value of the index \( n_0 \) at long wavelengths, i.e. the lattice contribution.

Walton and Moss [3] have measured the index of single crystals in the range 4.5 \( \mu \) to 8 \( \mu \). The samples had 10\(^{18}\) carriers per \( \text{cm}^3 \) and their effect was considered negligible at these wavelengths. They found \( n_\infty = 5.64 \pm .03 \) and \( \lambda_0 = 1.27 \mu \).

At long wavelengths as \( n_0 \) approaches to \( n_\infty \) the measured index \( n \) is determined largely by the carriers according to relation (1), which for

\[
g^2 \ll \omega^2 \quad \kappa^2 \ll n^2
\]
becomes

\[ n^2 = n_0^2 - \frac{N e^2}{m^* \varepsilon_0} \cdot \frac{\lambda^2}{4 \pi^2 c^2}. \quad (5) \]

Thus plotting \( n^2 \) versus \( \lambda^2 \) should give a straight line, with slope yielding carrier concentration. In practice we did not have enough points at long wave to avoid the edge dispersion region. Using the indices found for the untreated sample a graph was plotted negligible in the treated sample, values of \( n_o \) were read from the lower line and used in relation (5) and \( n \) was calculated for various values of carrier concentration. An effective mass was inserted from values obtained optically for \( n \)-type crystals by Walton, Moss and Ellis [4] as the monolayers are believed to be \( n \)-type. Values for \( p \)-type crystals are not very different however [5, 6, 7].

Figure 2 shows curves calculated for \( n \) versus \( \lambda \) for various carrier concentrations. Our experimental values of index are plotted also. It is evident from the fit at long waves that after heat treatment carrier concentration is less than \( 5 \times 10^{17} \) per \( \text{cm}^3 \); this concentration affects the measured index by approximately \(-0.25 \% \) at 10 \( \mu \), \(-0.13 \% \) at 8 \( \mu \), and can be neglected below 8 \( \mu \). Thus the extrapolation for the heat-treated sample is not significantly in error and yields the results

\[ n_\infty = 5.74 \pm .03 \]

\[ \lambda_0 = 1.379 (\pm .007) \mu \]
The fit in figure 3 yields the following carrier concentrations:

Before treatment: $4 \times 10^{18}$ per cm$^3$ ($\pm 1 \times 10^{18}$)

After treatment: $3 \times 10^{17}$ per cm$^3$ ($\pm 1 \times 10^{17}$)

The curves show the effect of $4 \times 10^{18}$ carriers per cm$^3$ is significant even at 4 $\mu$, and to deduce the form of the edge dispersion in a sample with this order of doping some re-iterative correction for carriers is necessary.

It is concluded then that the heat-treatment reduced carrier concentration by roughly a factor of 10.

Absorption indices can only be estimated to be between wide limits in this monolayer, and others on silicon, owing to a consistent loss of transmission throughout the wavelength range. This appears to be wavelength independent and does not occur on germanium substrates. Greater precision in determining $\kappa$, and hence the damping constant, should be possible using germanium. For this monolayer on silicon it cannot be concluded whether the damping increases or decreases on heat treatment.

Analysis of the dispersion of other monolayers has yielded carrier concentrations spread between $7 \times 10^{17}$ per cm$^3$ and $4 \times 10^{18}$ per cm$^3$, before heat treatment. In some cases damping constant can be estimated revealing a wide spread in this parameter. For example two films of 2 $\mu$ thickness, deposited on Si at 300 $^\circ$C from two different types of source revealed the following estimates:

<table>
<thead>
<tr>
<th>Source</th>
<th>$N$</th>
<th>$g$</th>
</tr>
</thead>
<tbody>
<tr>
<td>Alumina crucible</td>
<td>$7 \times 10^{17}$ per cm$^3$</td>
<td>$\omega \approx g$ at $\lambda = 25 \mu$</td>
</tr>
<tr>
<td>Ta boat</td>
<td>$3 \times 10^{18}$ per cm$^3$</td>
<td>$\omega^2 \gg g^2$ at $\lambda = 56 \mu$</td>
</tr>
</tbody>
</table>

In the first case the free carrier dispersion was found to be anomalous at 24 $\mu$, as compared with its trend up to 10 $\mu$, in a manner which can only be explained if $g$ is comparable with $\omega$. In the second case there was no such index anomaly up to 56 $\mu$ at least.

3. The heat treatment process. — Experiments have been performed to observe both the shift and increase in extrema as functions of time during the heat treatment process. Samples were heated for a short interval, cooled and measured and the cycle repeated to obtain time and temperature dependent behaviour. The process is found to be exponential with time and the limiting time is itself an exponential function of temperature (characteristic of a rate process). An approximate fit is obtained to a relation of the form

$$t = A \exp \left( \frac{E_w}{kT} \right)$$

where $E_w = 0.83$ eV.

For instance, for samples heated at 320 $^\circ$C, no further change could be observed after about 10 minutes at atmospheric pressure; whereas at 270 $^\circ$C the corresponding time is 3 hours. Scanlon [8] reports studies on the heat treatment of PbTe crystals with excesses of Pb and Te. Such excesses are believed to exist as interstitial atoms which can be diffused out and precipitated at dislocations or grain boundaries by annealing. However, the rates involved are different by orders of magnitude: Scanlon’s results for $n$-type PbTe rich in Pb show a time of 50 hours is required at 400 $^\circ$C to reduce carrier concentration from $7.8 \times 10^{17}$ per cm$^3$ to $2.5 \times 10^{17}$ electrons/cm$^3$. In $p$-type PbTe rich in Te a sample of $10^{18}$ carriers per cm$^3$ heated at 294 $^\circ$C reached an equilibrium value...
of $4.8 \times 10^{17}$ carriers per cm$^3$ after 40 hours, and he reports similar results are obtained in vacuo, or air.

Our heat treatment, for evaporated thick films, is found to require the presence of oxygen. Similar effects are observed at reduced pressures if heating is continued for several days but it is not clear whether this is a different process or the same one at reduced rate due to reduced oxygen pressure.

4. Discussion. — Table 1 summarises some other measurements which have been made on the monolayers, including in the first row the dispersion results discussed above.

<table>
<thead>
<tr>
<th>Sample</th>
<th>Measurement</th>
<th>Heat treatment</th>
<th>No. of carriers per cm$^3$, $N$</th>
<th>Type of carrier</th>
<th>Damping constant, $g$, sec$^{-1}$, cm$^3$ sec$^{-1}$</th>
<th>$\frac{g}{N}$, cm$^3$ sec$^{-1}$</th>
</tr>
</thead>
<tbody>
<tr>
<td>2.06 microns, on Si</td>
<td>Dispersion</td>
<td>Before</td>
<td>$4 \times 10^{18}$</td>
<td>—</td>
<td>$(4.2 - 1.5) \times 10^{12}$</td>
<td>—</td>
</tr>
<tr>
<td>~ 4 microns, on Ge</td>
<td>Faraday (1)</td>
<td>—</td>
<td>$3 \times 10^{17}$</td>
<td>—</td>
<td>—</td>
<td>—</td>
</tr>
<tr>
<td>~ 2 microns, on Ge</td>
<td>Plasma (3)</td>
<td>—</td>
<td>$4 \times 10^{18}$</td>
<td>n</td>
<td>—</td>
<td>—</td>
</tr>
<tr>
<td>~ 1 micron, on fused quartz</td>
<td>Resistivity (2)</td>
<td>Before</td>
<td>$1 \times 10^{18}$</td>
<td>—</td>
<td>—</td>
<td>—</td>
</tr>
<tr>
<td>~ 2 microns, on glass</td>
<td>Hall (4)</td>
<td>—</td>
<td>$4 \times 10^{16}$</td>
<td>n</td>
<td>$3.6 \times 10^{-5}$</td>
<td>$1.8 \times 10^{-2}$</td>
</tr>
<tr>
<td>Source material (granules), prior to evaporation</td>
<td>Seebeck (4)</td>
<td>—</td>
<td>$10^{19}$</td>
<td>p</td>
<td>—</td>
<td>—</td>
</tr>
</tbody>
</table>

(1) Preliminary measurement.
(2) Preliminary measurement, assumes $m^* = .13 m_o$ and calculates $g$ from mobility.
(3) Most samples do not show plasma effect: inference is that this sample has lower than typical $g$.
(4) See reference [9].

With regard to the source material, the purity of the Pb used is 99.9999%, and the Te 99.999% containing not more than 10 parts per million of Se. The materials are weighed [9] before granulation in stoichiometric proportions to 1 part in $10^5$. It can be inferred that the concentration of $10^{19}$ p-type carriers arises by crystals solidifying out with excess Te in their lattices, with free Pb solidified external to the lattice. Phase diagrams [10] suggest this is likely.

It is possible that such an excess of Te could be altered to an excess of Pb in the evaporation and deposition of the material, owing to the different vapour pressures of Pb, Te and PbTe, (Te is the most volatile and could evaporate faster and may re-evaporate from the heated substrate. For a vapour pressure of $10^{-5}$ torr Pb requires 485°C and Te 242°C [11]). So far, no significant difference in transparency has been found between monolayers deposited successively from the same source charge.

Experiments have been performed to compare the effect of different substrate temperatures under otherwise similar conditions, depositing on germanium. Differences were found at 300°C, 200°C and 100°C with respect to longwave transparency, the best result being at 200°C, and the worst at 300°C, but the differences were slight when compared with the effects of different source arrangements and different substrates.

A simultaneous deposition on Si, Si with a thin ZnS layer, Ge and Ge with a thin ZnS layer, at 300°C produced marked differences in transparency. The worst result was on Si and was accompanied by a microscopic mosaic of cracks in the PbTe layer at spacings between 10 and 50μ. The transparency was improved on both Ge and Si by the presence of ZnS, correlated with a reduction in the extent of the cracking. (The cracking may arise from mismatch of thermal expansions, which is greatest in Si and least in ZnS. Whether it is accompanied by smaller scale defects which can affect carrier mobilities is a matter of conjecture).
Equally significant differences in transparency have been found in depositing onto Si at 300 °C from various types of source. Indirectly-heated alumina crucibles and quartz dishes give markedly better results than Mo or Ta resistance-heated boats. It appears in fact that heat treatment of the boat-produced layers yields transparency roughly equal to that of untreated crucible-produced films. Furthermore in one case an evaporation from a shallow dish of quartz produced a monolayer of the highest transparency which was slightly degraded on heat treatment with spectral shift to shorter wavelengths, indicating a tendency towards increase of carriers.

It will be evident that there is still some difficulty in producing consistently transparent monolayers of PbTe but measurement of carrier properties is providing some clues to achieving this.

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Most of the depositions were carried out by Mr. R. Hunneman.

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